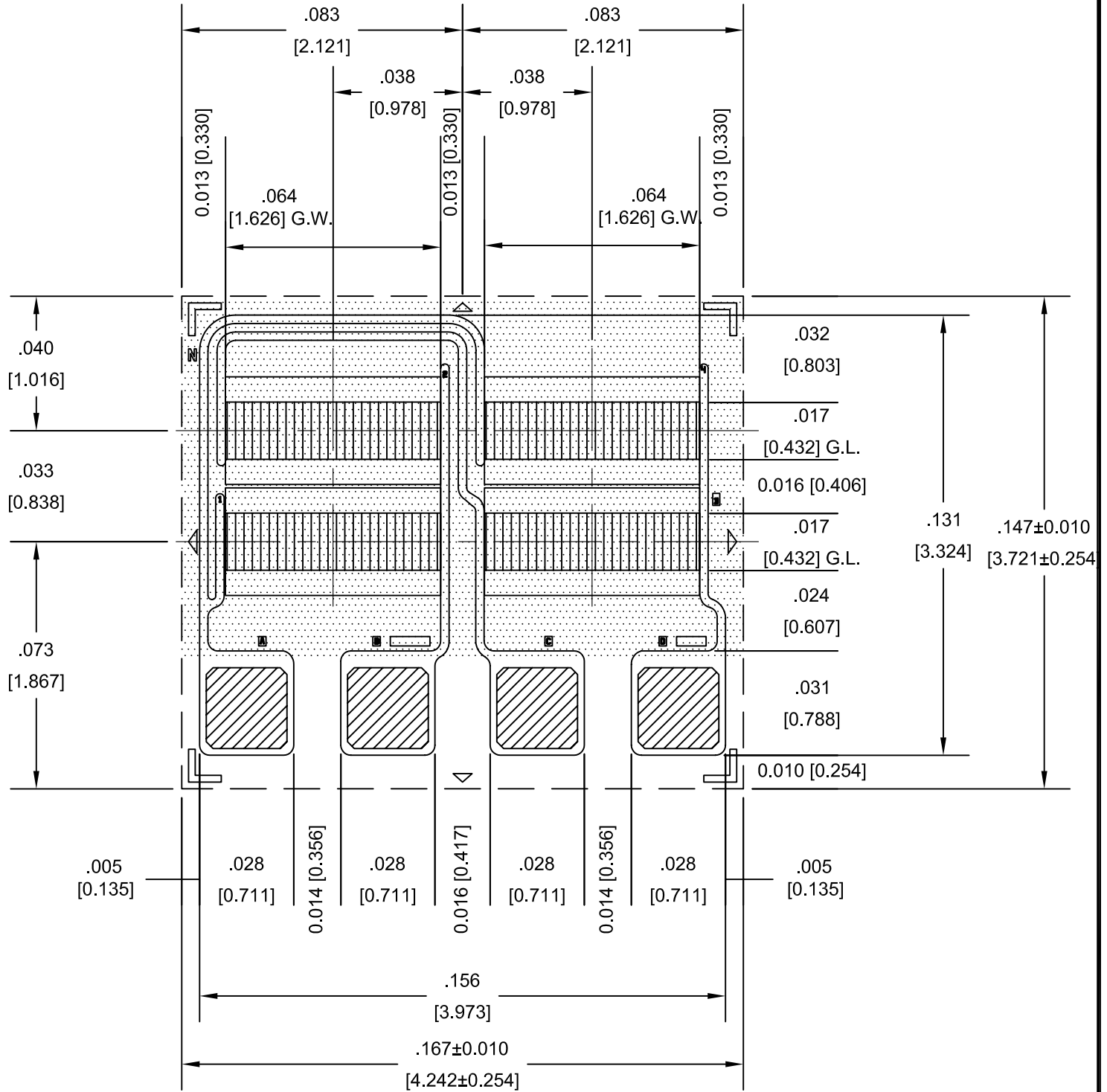


LTR	REVISION	ERN	INITIAL	DATE
~			AR	2012-09-13



* THESE MATRIX RELATED DIMENSIONS ARE ±0.005

THESE DRAWINGS/SPECIFICATIONS ARE THE EXCLUSIVE PROPERTY OF MICRO-MEASUREMENTS. THEY SHALL NOT BE REPRODUCED OR COMMUNICATED TO OTHERS, IN WHOLE OR IN PART, NOR BE USED AS A BASIS FOR MANUFACTURE OR SALE OF THE ITEMS REPRESENTED, WITHOUT THE WRITTEN PERMISSION OF MICRO-MEASUREMENTS.



Micro-Measurements
Raleigh, North Carolina USA



S5072 PATTERN LAYOUT

CONSTRUCTION:

N5K

OPTIONS:

G, E3

RESISTANCE:

1000±0.2%
BALANCED TO ±0.4mV/V

REFERENCE:

DRAWN BY:

A.R.

DATE:

2012-09-13

SCALE:

N.T.S.

ALL DIMENSIONS ARE IN INCHES
UNLESS OTHERWISE SPECIFIED.

PROJ. ENG.

G.Y.

DATE:

2012-09-13

DWG. #

MS-S5072-10061

REVISION:

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